Appl. No. 10/788,689 Amdt. dated Aug. 29, 2005 Reply to Office Action of May 27, 2005

Amendments to the Specification

Please replace paragraph [0019] with the following amended paragraph:

[0019] The masking film 413 is provided on the light emitting surface
412d for blocking external UV rays. The masking film 413 may be made of
a suitable material, such as a transparent transparent metal oxide or SiO₂,
which has the ability to block UV rays. The masking film 413 may be
formed on the light emitting surface 412d by printing or by laser deposition.
Alternatively, the masking film 413 may be attached to the light emitting
surface 412d. A thickness of the masking film 413 is from 0.3 micrometers
to several micrometers.